

## Supporting Information

### Ultrasensitive NO<sub>2</sub> gas sensor based on hierarchical Cu<sub>2</sub>O/CuO

#### mesocrystals nanoflower

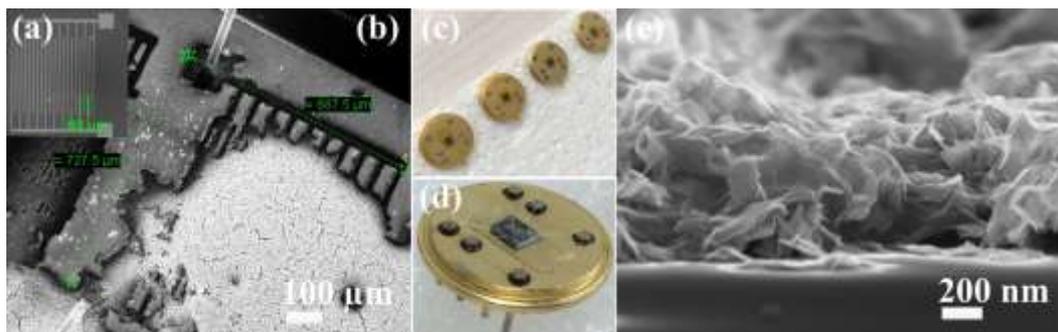
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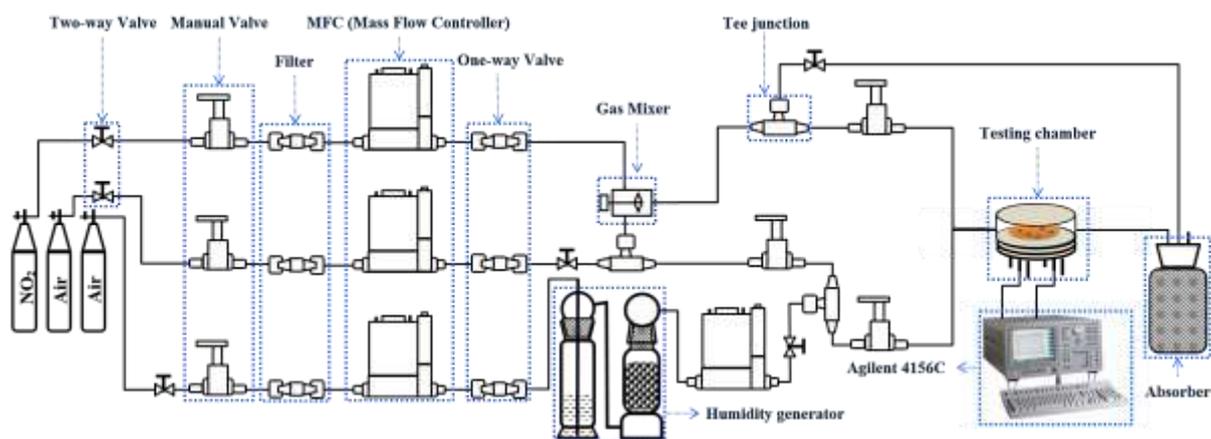
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## S1. Gas sensor electrode and device images



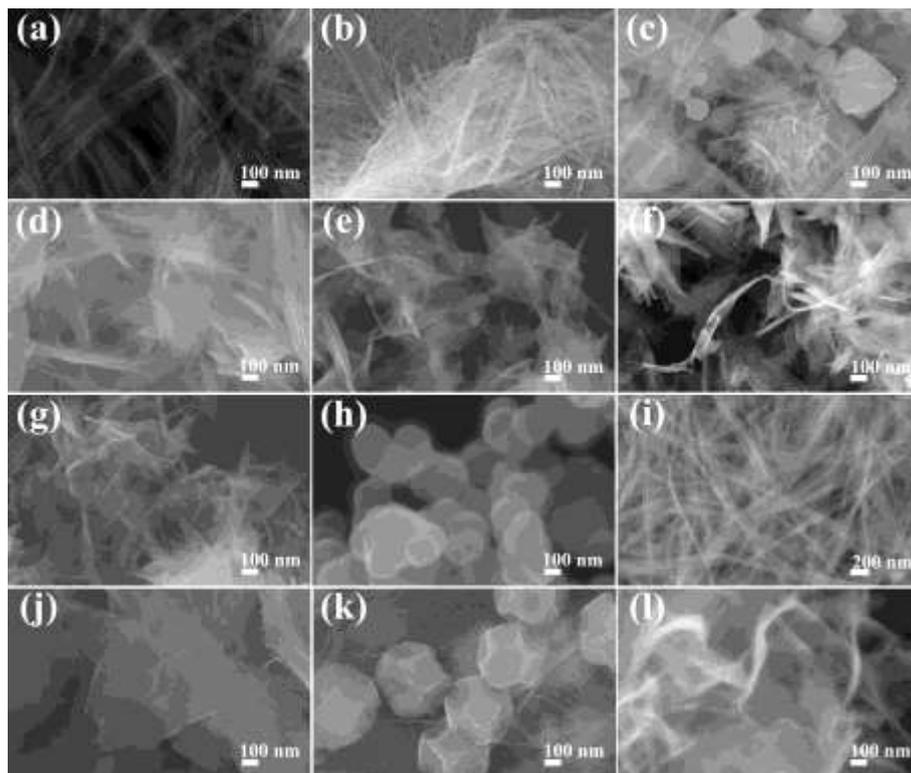
**Fig. S1** SEM/digital images of the sensor device: the SEM images of the interdigital electrode unit (a) before and (b) after dropping sample, (c-d) the digital images of the electrode on metal base, (e) the cross-section SEM image of the sensor device.

## S2. Gas sensing testing system



**Fig. S2** Schematic diagram shows the gas sensor testing system.

### S3. SEM characterizations of hierarchical $\text{Cu}_2\text{O}/\text{CuO}$ mesocrystals

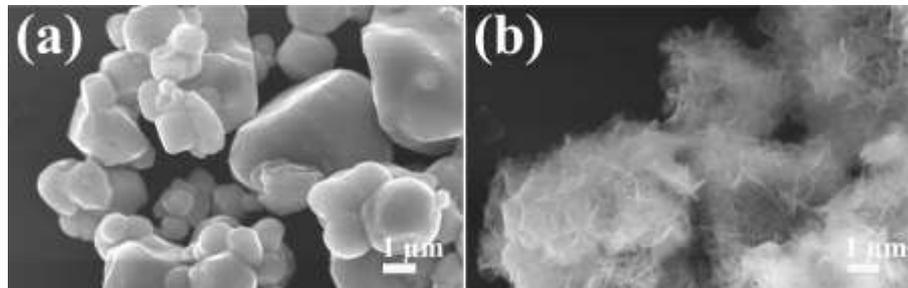


**Fig. S3** (a-l) SEM images of lamellar  $\text{Cu}_2\text{O}$ -oleate complex intermediate.

**Table S1** The corresponding reaction condition for the samples in Fig. S3

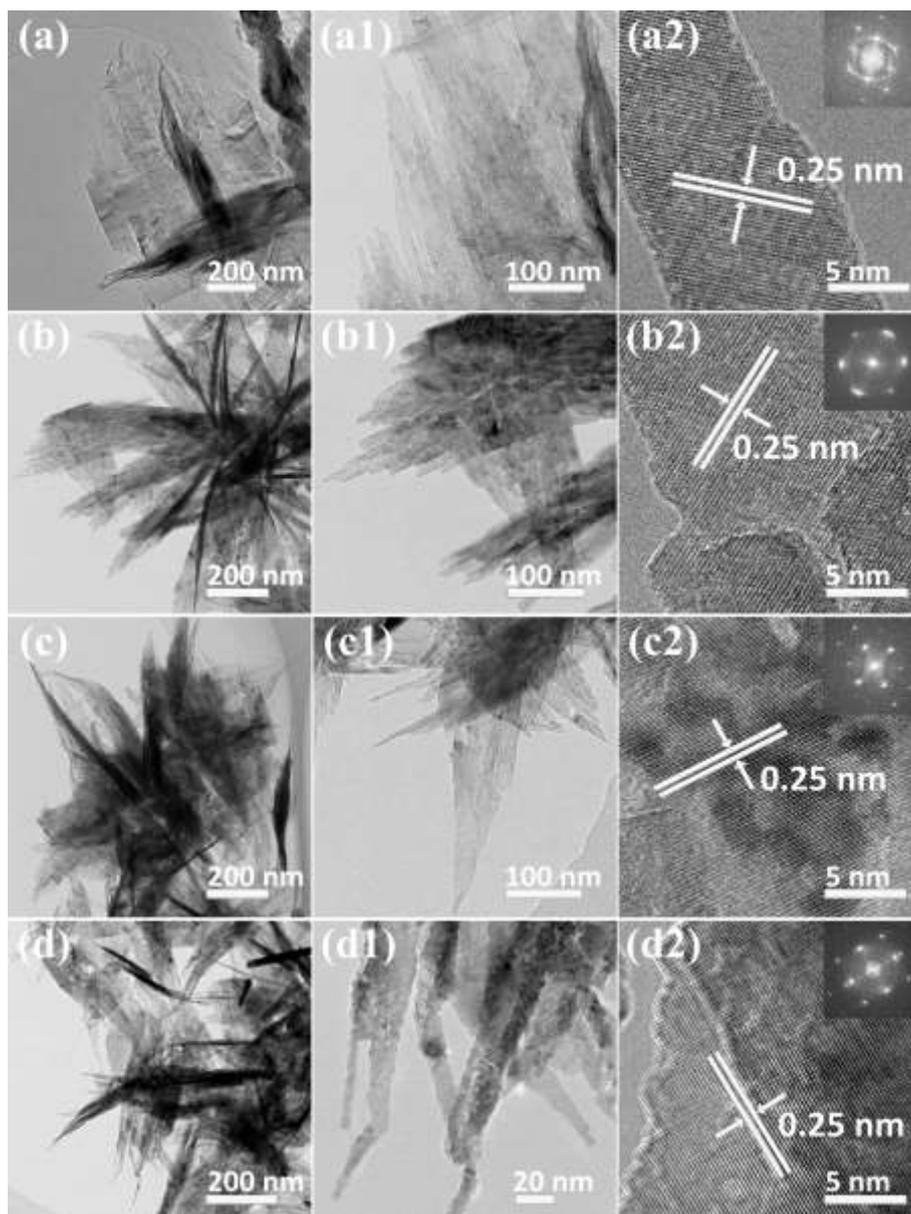
Synthesis condition	Temperature/°C	NaOH/M	N <sub>2</sub> H <sub>4</sub> ·H <sub>2</sub> O/M	Cu <sup>2+</sup> /M	Time (h)
(a)	25	0.0175	0	0.001	10
(b)	25	0.0175	0.0008	0.001	10
(c)	25	0.0175	0.001	0.001	10
(d)	25	0.0175	0.002	0.001	10
(e)	25	0.0175	0.0035	0.001	10
(f)	25	0.0175	0.0075	0.001	8
(g)	25	0.0175	0.015	0.001	6
(h)	25	0	0.0035	0.001	10
(i)	25	0.0375	0.0035	0.001	10
(j)	25	0.125	0	0.001	20
(k)	10	0.0175	0.0035	0.001	10
(l)	25	0.25	-	Replaced by 0.5 g Cu <sub>2</sub> O	12

**S4. Morphology comparison of comercial Cu<sub>2</sub>O before and after reaction**

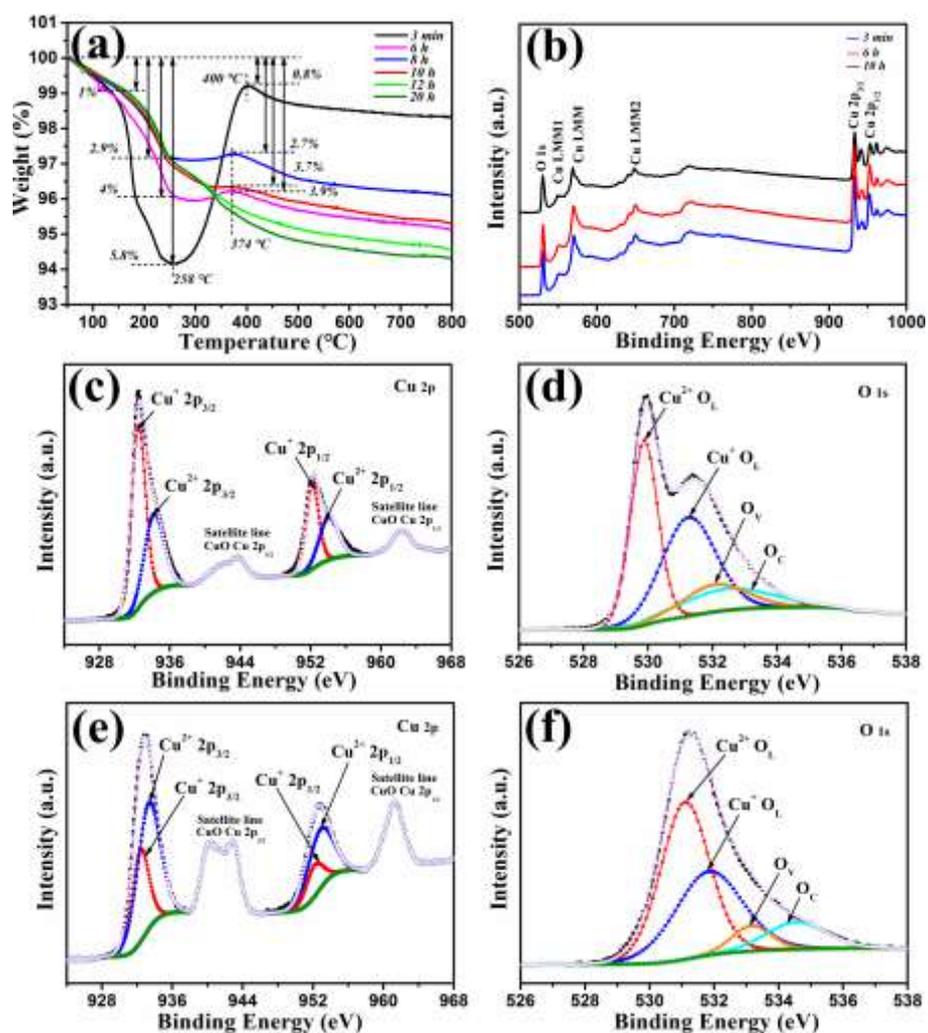


**Fig. S4** SEM images of comercial Cu<sub>2</sub>O before (a) and after (b) reaction.

## S5. Morphology comparison of Cu<sub>2</sub>O/ CuO-10 composite with different copper salts



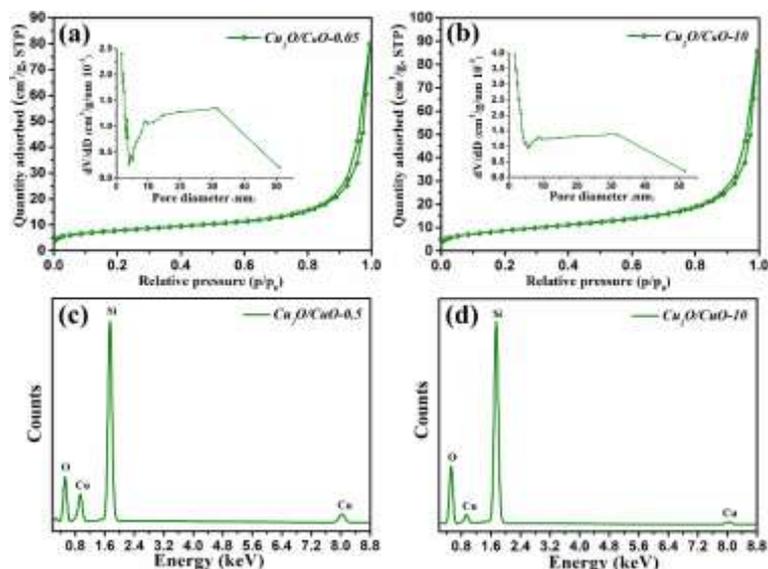
**Fig. S5** Typical TEM images with different magnification and HRTEM images of Cu<sub>2</sub>O/ CuO-10 composites obtained with different copper salts: (a-a2) CuSO<sub>4</sub>, (b-b2) CuCl<sub>2</sub>, (c-c2) Cu(NO<sub>3</sub>)<sub>2</sub>, (d-d2) Cu(CH<sub>3</sub>COO)<sub>2</sub>.



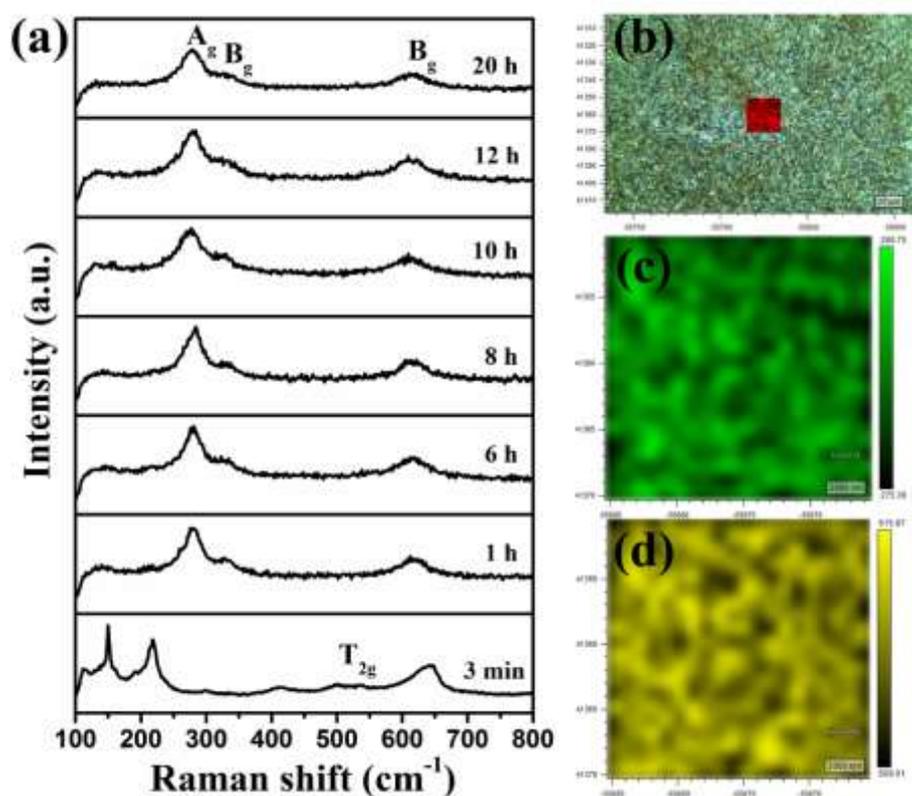
**Fig. S6** (a) TGA curves of sample obtained at 3 min, 6 h, 8 h, 10 h and 20 h; (b) Complete XPS spectra of the samples at 3 min, 6 h and 10 h; (c-d) Cu 2p XPS and O1s XPS spectra of the sample at 3 min; (e-f) Cu 2p XPS and O1s XPS spectra of the sample at 10 h.

**Table S2** Results of curve fitting of Cu 2p XPS spectra of the samples.

Sample	Cu 2p <sub>3/2</sub>	Cu <sup>+</sup> 2p <sub>3/2</sub>	Cu <sup>2+</sup> 2p <sub>3/2</sub>	Cu 2p <sub>1/2</sub>	Cu <sup>+</sup> 2p <sub>1/2</sub>	Cu <sup>2+</sup> 2p <sub>1/2</sub>
Cu <sub>2</sub> O/CuO-0.05	932.5 eV	932.5 eV	934.2 eV	952.3 eV	952.3 eV	954.2 eV
Cu <sub>2</sub> O/CuO-10	933.0 eV	932.6 eV	933.5 eV	952.8 eV	952.6 eV	953.3 eV

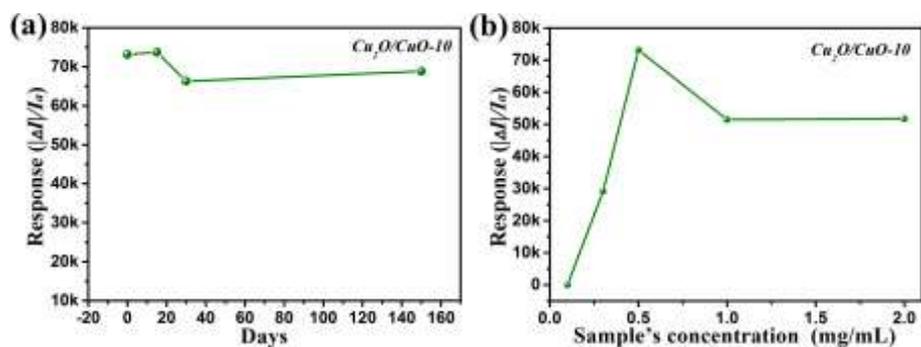


**Fig. S7** N<sub>2</sub> adsorption-desorption isotherm and pore size distribution (inset) of sample obtained at 0.5 h (a) and 10 h (b). EDX spectrum of sample obtained at 0.5 h (c) and 10 h (d).



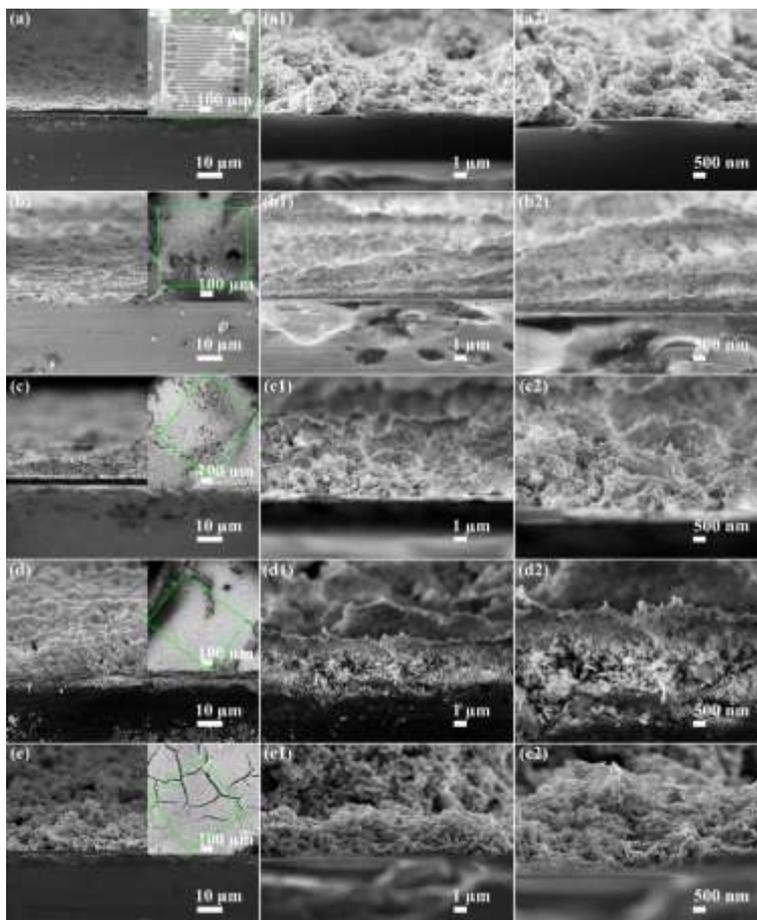
**Fig. S8** (a) Raman spectra of sample obtained at 3 min, 1 h, 6 h, 8 h, 10 h, 12 h and 20 h; (b) Digital Photo of sample obtained at 10 h; (c-d) Raman mapping scanning of samples obtained at 10 h with 278 and 615 cm<sup>-1</sup> as the characteristic peak positions.

**S9. The stability of the Cu<sub>2</sub>O/CuO-10 sensors and the sensing performance of devices with different sample concentration**



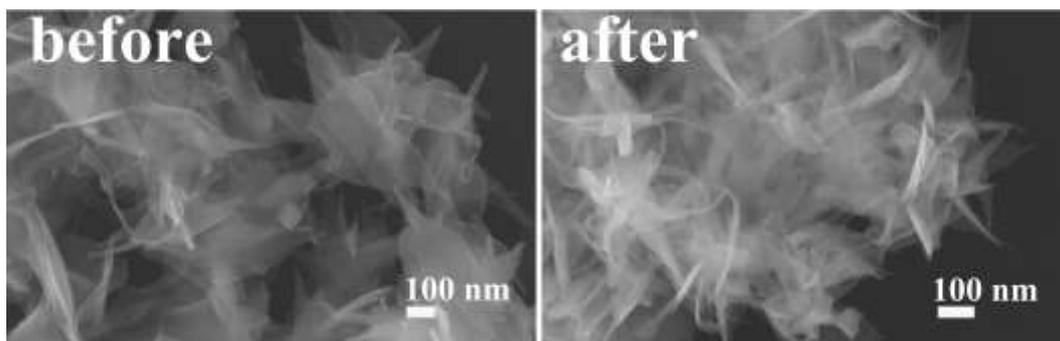
**Fig. S9** The response of the fresh fabricated Cu<sub>2</sub>O/CuO-10 sensors exposure to 10 ppm NO<sub>2</sub> within 100 s (a) in 150 days and (b) with different sample concentrations.

**S10. Morphology comparison of the prepared CuO/Cu<sub>2</sub>O-10 sensor device with different sample concentrations**



**Fig. S10** The cross-section SEM images of the prepared CuO/Cu<sub>2</sub>O-10 sensor device with different sample concentrations: (a-a2) 0.1 mg/mL, (b-b2) 0.3 mg/mL, (c-c2) 0.5 mg/mL, (d-d2) 1.0 mg/mL, (e-e2) 2.0 mg/mL. The insets are corresponding top view SEM images of the substrate.

**S11. Morphology comparison of the prepared CuO/Cu<sub>2</sub>O-10 composite before and after NO<sub>2</sub> sensing response**



**Fig. S11** SEM images of the prepared CuO/Cu<sub>2</sub>O-10 composite before and after NO<sub>2</sub> sensing response.